Epitaxial Growth of Nearly Lattice Matched Core-Shell GaAs/Pb_{1-x}Sn_xTe Nanowires



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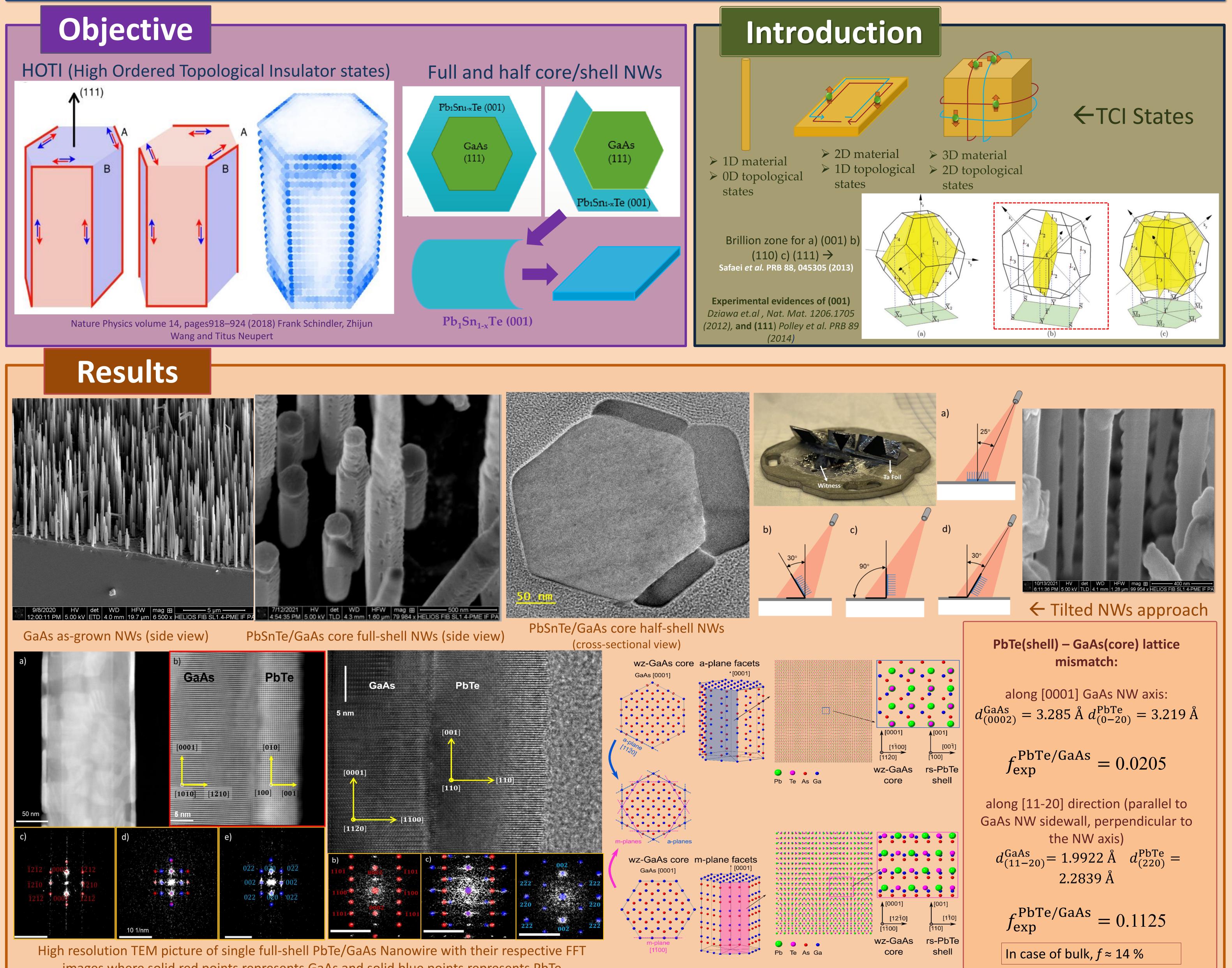
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Motivation

The nanowire heterostructures enable bandgap engineering in a one-dimensional nanostructure. In the planar semiconductor heteroepitaxial systems, typically large lattice mismatch results in the low-quality interfaces and high dislocation densities, which further degrade the electrical properties of material. These effects can be avoided in the nanostructures, due to the nanoscale dimensions. Here, we studied full and half-shells of IV-VI narrow gap semiconductors on III-V nanowires (NWs). The topological crystalline insulator Pb₁.

_xSn_xTe alloy is chosen as a shell material that possesses the band inversion property for some critical concentration of Sn.



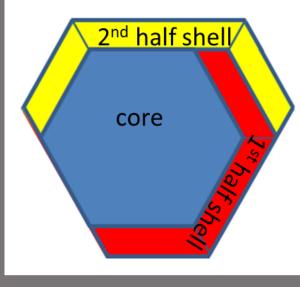
images where solid red points represents GaAs and solid blue points represents PbTe

Conclusions

- We are able to grow full and half shells of IV-VI on III-V nanowires
- It's easier to grow smooth and unbroken shells on inclined nanowires as compared to perpendicular one
- We got nearly lattice matched shell on the side walls of (-110) GaAs nanowire

Future plans:

- To obtain completely smooth and unbroken coreshell nanowires to observe their TCI states and expected HOTI states
- To grown second half shell on the side of nanowires



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